



**Department of Chemistry  
University of Delhi, Delhi – 110 007**

Applications are invited for the post of **Junior Research Fellow (JRF, one post)** to work in the CSIR project entitled “**Sustainable metal-catalyzed oxidative tandem reactions: exploring novel approaches for synthesis of biologically relevant nitrogen-containing heterocycles**” – [02(0332)/18/EMR-II] under the supervision of Dr. Kovuru Gopalaiah. Appointment will be made as per CSIR guidelines for JRF position and detailed requirements are given below.

**Eligibility**

- a) Candidate must possessing M.Sc. degree in Chemistry or equivalent degree with 55% marks and passing of NET/GATE.
- b) The candidate with background and inclination towards Organic Chemistry in M.Sc. will be preferred.

Employed candidates, whether temporary or permanent, and those who have already availed higher fellowships like SRF, RA, etc., will not be considered for JRF position.

**Age Limit**

The upper age limit for applying to the post of JRF shall be 28 years as on the last date of application. The upper age limit is relaxable upto 5 years in the case of applicants belonging to SC/ST/OBC/Women and physically handicapped candidates.

**Duration of Fellowship**

Tenure of the fellowship is till 31<sup>st</sup> May 2021.

**Stipend**

JRF: Rs.31,000/- pm plus House rent allowance (HRA) and Medical allowance (MA) as per CSIR norms.

**Nature of Work**

Synthesis, purification and characterization of organic compounds having biological properties.

Eligible candidates are requested to send a copy of resume along with the attested copies of the certificates (educational certificates from class 10th to M.Sc. degree, NET/GATE certificate, proof of date of birth, copy of caste certificate) to Dr. Kovuru Gopalaiah, Department of Chemistry, University of Delhi, Delhi-110007. E-Mail: [gopalaiah@gmail.com](mailto:gopalaiah@gmail.com) on or before **27<sup>th</sup> October 2020**. Suitable candidates will be called for interview (preferably online). No TA/DA will be provided for attending the interview.